

### Comment on "Phase Transition in a Restricted Solid-on-Solid Surface-Growth Model in 2+1 Dimensions"

In a recent Letter,<sup>1</sup> Amar and Family (AF) have done extensive numerical simulations of surface growth in  $d=2+1$  with a finite-temperature restricted solid-on-solid (RSOS) growth model.<sup>2</sup> They find an unusual transition as a function of their parameter  $\kappa$  which plays the role of an inverse temperature. In this Comment, we propose an explanation of their results based on a continuum growth model. We argue that the observed "transition" is not due to a nonequilibrium analog of a roughening transition, but to the vanishing of the coefficient  $\lambda$  of the nonlinear term in the Kardar-Parisi-Zhang (KPZ) equation of a growing interface.<sup>3</sup>

We assume that the interface is always rough at long length scales,<sup>4</sup> so that in the continuum limit the growth subject to a height restriction may be described by

$$\partial h/\partial t = \mu e^{-a(\nabla h)^2} [1 + b\nabla^2 h + c(\nabla h)^2 + \dots],$$

where  $h(\mathbf{x}, t)$  is the height of the interface on a  $(d-1)$ -dimensional substrate,  $a$ ,  $b$ , and  $c$  are positive constants,  $\mu$  is the random deposition rate with  $\langle \mu \rangle = \mu_0$ , and

$$\langle [\mu(\mathbf{x}, t) - \mu_0][\mu(\mathbf{x}', t') - \mu_0] \rangle = 2D\delta(\mathbf{x} - \mathbf{x}')\delta(t - t').$$

The exponential term represents a height restriction with strength  $a$ . Expanding this term and neglecting irrelevant higher-order terms one recovers the KPZ equation<sup>3</sup>  $\partial h/\partial t = v\nabla^2 h + \lambda(\nabla h)^2 + \mu$ , with  $v = \mu b$  and  $\lambda = \mu \times (c - a)$ . For the RSOS model with  $\kappa = 0$ ,  $\lambda$  is negative<sup>5</sup> since some step sites are unavailable for growth. However, increasing  $\kappa$  will increase  $b$  since deposition at a step edge becomes more favorable than on a flat surface which, because of irreversibility, causes  $c$  to increase. A "peak" for which  $\nabla^2 h < 0$  can neither evaporate nor spread out, and  $c$  must increase to cancel the effect of the negative  $\nabla^2 h$  term. Since  $a$  remains constant there exists a  $\kappa_c$  for which the effective  $\lambda$  is zero. This case of an ideal interface can be solved exactly with exponents<sup>6</sup>  $\beta = \alpha = 0$  in  $d=2+1$ . Thus, a logarithmic growth is expected at  $\kappa_c$ , as observed by AF. Moreover, since the sign of  $\lambda$  is irrelevant, the growth exponent should remain intact for  $\kappa > \kappa_c$ . The same conclusion can be obtained from a more microscopic argument. For  $\kappa > 0$  the growth on step edges becomes more favorable than on the flat areas, and thus  $\lambda$  must be positive for large  $\kappa$ .

We can estimate the value of  $\kappa_c$  in  $d=2+1$  with a simple argument. Namely, the growth rate of a step edge is proportional to  $e^{-2\kappa}$ , while that of the flat region is  $e^{-4\kappa}$ . Simulations give the result<sup>5-7</sup> that about one-third of the sites are active (for  $\kappa = 0$ ). Equating  $\frac{1}{3}e^{-2\kappa}$

to  $e^{-4\kappa}$  gives  $\kappa_c > (\ln 3)/2 = 0.55$ . In higher dimensions, kinks in steps must be taken into account which leads to a lower value of  $\kappa_c$ . This argument also implies that the size of a flat region will be  $\sim e^{2\kappa}$ , so that finite-size effects will be very severe for large  $\kappa$ .

As a consequence of our arguments, in  $d=1+1$  there should be a change in the exponent  $\beta$  from the value of  $\frac{1}{3}$  to  $\frac{1}{4}$  at  $\kappa_c$ , while  $\alpha = \frac{1}{2}$  remains unchanged. We have done simulations of the AF model with  $\rho = 0$  and find that  $\beta$  indeed decreases from its  $\kappa = 0$  value to the ideal surface value of  $\frac{1}{4}$  at  $\kappa_c$ . We estimate that  $0.8 < \kappa_c < 1.2$ . For  $\kappa = 2.0$ , the effective value of  $\beta$  increases from  $0.27 \pm 0.01$  ( $L = 2000$ ) up to  $0.30 \pm 0.01$  ( $L = 4000$ ), and for  $\kappa = 3.0$  from  $0.28 \pm 0.01$  ( $L = 1200$ ) to  $0.31 \pm 0.01$  ( $L = 4000$ ). For smaller systems ( $L = 400$ ) it was not possible to obtain meaningful exponents for  $\kappa > 2$ . On the other hand, we get  $\alpha = 0.5 \pm 0.02$  at both  $\kappa = 1$  and 2, as expected. All these numerical results are consistent with the idea that growth using the AF algorithm can be explained by the KPZ equation with  $\lambda = 0$  at  $\kappa_c$ . The effective exponents observed by AF for  $\kappa > \kappa_c$  are due to the large effective microscopic length scale compounded by a very slow crossover from the ideal interface behavior in  $d=2+1$ .

J. M. Kim thanks M. Moore and A. Bray for useful discussions. This work was supported by NSF Grant No. DMR 89-18358 (J. M. Kosterlitz), an ONR grant (T.A.-N.), and the United Kingdom Science and Engineering Research Council (J. M. Kim).

J. M. Kim  
Department of Theoretical Physics  
The University  
Manchester M13 9PL, United Kingdom

Tapio Ala-Nissila and J. M. Kosterlitz  
Department of Physics  
Brown University  
Providence, Rhode Island 02912

Received 16 February 1990  
PACS numbers: 61.50.Cj, 05.40.+j

<sup>1</sup>J. G. Amar and F. Family, Phys. Rev. Lett. **64**, 543 (1990).

<sup>2</sup>J. M. Kim and J. M. Kosterlitz, Phys. Rev. Lett. **62**, 2289 (1989).

<sup>3</sup>M. Kardar, G. Parisi, and Y. Zhang, Phys. Rev. Lett. **56**, 889 (1986).

<sup>4</sup>P. Nozieres and F. Gallet, J. Phys. (Paris) **48**, 353 (1987).

<sup>5</sup>J. M. Kim, Ph.D. dissertation, Brown University, 1989 (unpublished).

<sup>6</sup>S. F. Edwards and D. R. Wilkinson, Proc. Roy. Soc. London A **381**, 17 (1982).

<sup>7</sup>J. M. Kim, J. M. Kosterlitz, and T. Ala-Nissila (unpublished).